

L Number	Hits	Search Text	DB	Time stamp
29	104	313/\$.ccls. and (carbon or organic) same sulfur and (conductor or semiconductor) and substrate	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:09
34	2	313/\$.ccls. and (carbon or organic) same sulfur same (mol or "%") and (conductor or semiconductor) and substrate	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:12
35	3	313/\$.ccls. and (carbon or organic) same sulfur same (mol or "%") and (conductor or semiconductor)	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:13
36	6	(313/\$.ccls. or 257/\$.ccls. or 252/\$.ccls) and (carbon or organic) same sulfur same (mol or "%") and (conductor or semiconductor)	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:13
38	220	313/\$.ccls. and organic and sulfur	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:16
37	294	313/\$.ccls. and carbon and sulfur	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:16
43	0	313/326.cccls. and (carbon and sulfur)	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:16
39	767	313/310.cccls.	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:16
40	21	313/310.cccls. and sulfur	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:16
41	10	(313/496.cccls. or 313/497.cccls.) and (carbon and sulfur)	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:16
42	4	313/346R.cccls. and (carbon and sulfur)	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:16
49	127	252/519.4.cccls.	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:18
44	11	313/311.cccls. and (carbon and sulfur)	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:18
45	371	313/\$.cccls. and film and sulfur	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:18
46	828	(carbon same sulfur) and ("image forming" or "electron emitting" or display) and film and electrode	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:20
47	354	(carbon same sulfur) and ("image forming" or "electron emitting" or display) and film and electrode not genes not human not (sulfur same impurities) not hexafluoride not photographic	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:20
48	844	313/495.cccls.	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:20
50	39	252/519.4.cccls. and carbon	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:20
51	11	252/519.4.cccls. and "thin film"	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:20
52	5	(313/306.cccls. or 313/308.cccls.) and sulfur	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:20
53	2	"6267636"	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:20
54	18	313/495.cccls. and (carbon and sulfur)	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:20

55	7	252/519.14.ccls. and carbon and sulfur	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:20
56	17	252/519.4.ccls. and carbon and sulfur	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:20
57	148	313/\$.ccls. and (carbon or organic) and sulfur and (conductor or semiconductor) and substrate	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:20
58	7	ohnishi and toshikazu and sulfur	USPAT; US-PGPUB; EPO; JPO	2002/06/14 14:20